

Physics-Informed Graph Neural Network for Circuit Compact Model Development

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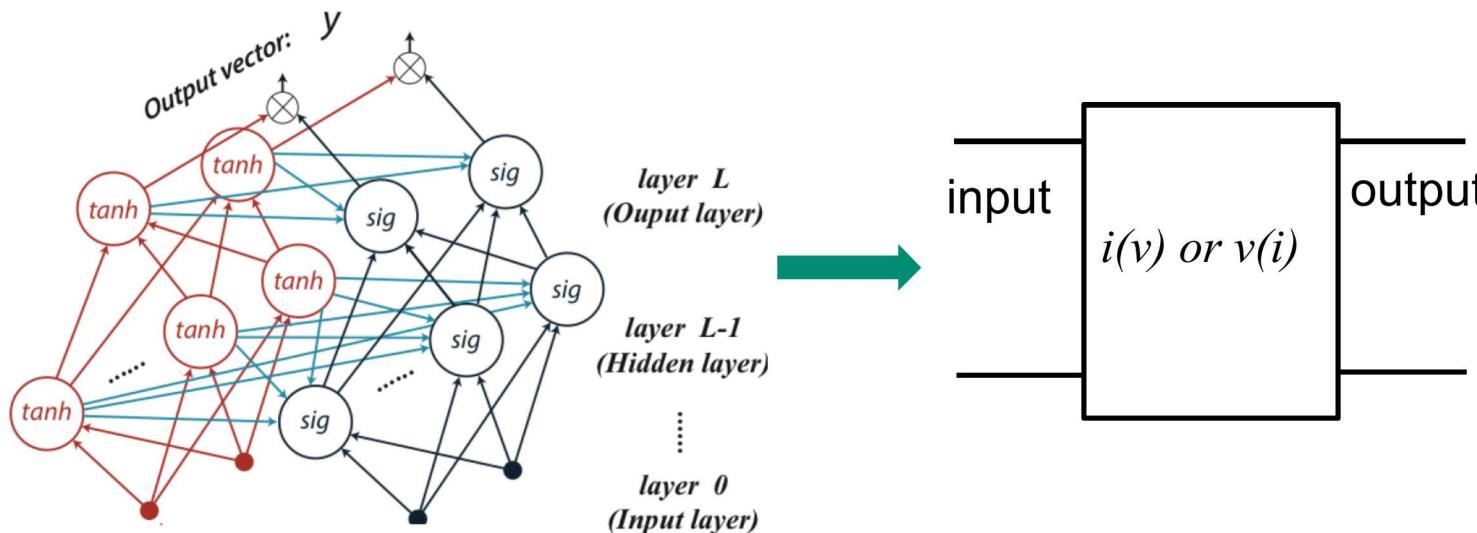


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Machine Learning for Compact Model Development

- Traditional compact model development (CMD) takes multi-years and multi-institutional efforts.
- Data-driven machine learning (ML) is being actively explored for fast CMD [1-2].



- ✓ Fast CMD (a functional black box)
- ✗ Physics-agnostic, may lead to unphysical predictions
- ✗ Ignore high-fidelity physics from TCAD simulation

New opportunity: combine TCAD physics and data-driven ML for rapid and physics-based circuit compact model development

- [1] M. Li, O. İrsoy, C. Cardie and H. G. Xing, IEEE J. Explor. Solid-State Computat. vol. 2, pp. 44-49, Dec. 2016.
- [2] K. Aadithya, P. Kuberry et al., arXiv:2001.01699, 2020.

pigNN-CMD Methodology

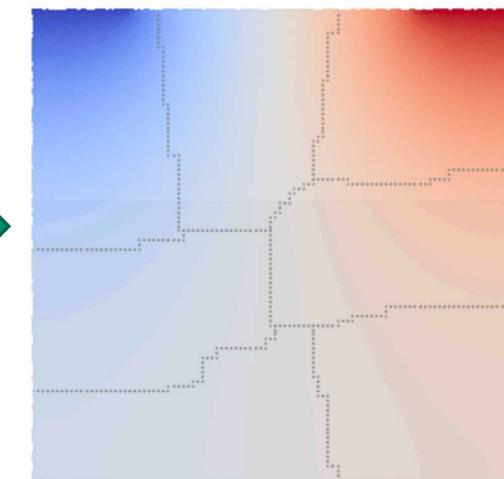
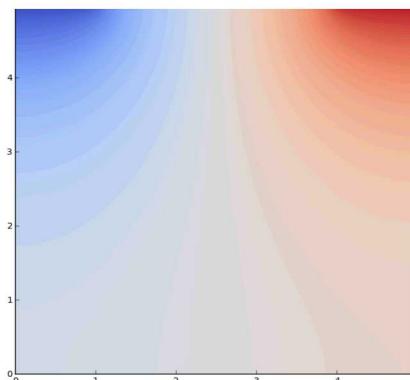
We propose **the physics-informed graph neural network (pigNN) methodology** for circuit CMD

Physics Priming (PP)
(Perfunctory TCAD)

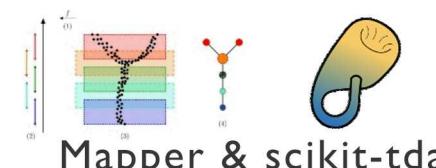
Region Recognition (RR)
(ML + TDA)

Topology Tailoring (TT)
(TCAD-informed ML)

Interaction Identification (II)
(seeded w/ established CMs)



**Loosely calibrated
TCAD simulations**



- Use machine learning (ML) classification and topological data analysis (TDA) methods to process TCAD physical fields
- Determine physically important regions as they evolve through a sweep of bias/time conditions.

pigNN-CMD Methodology

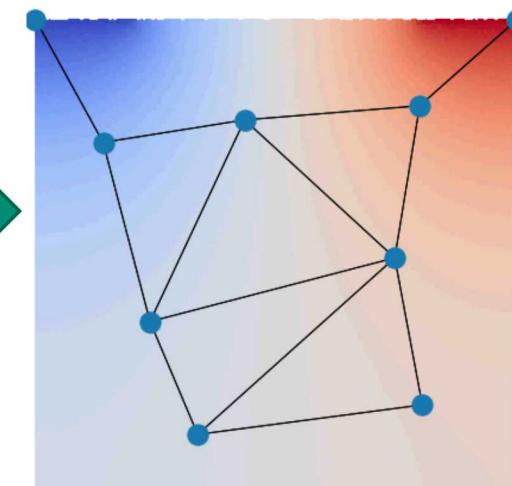
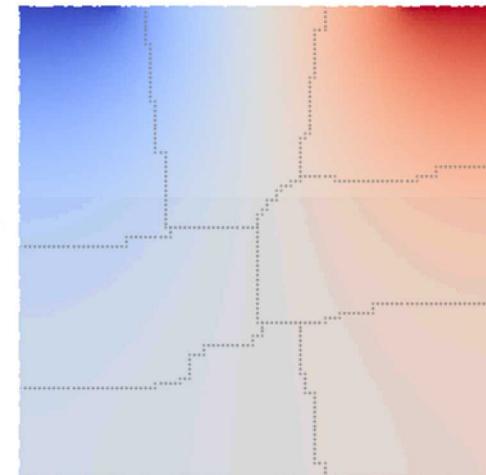
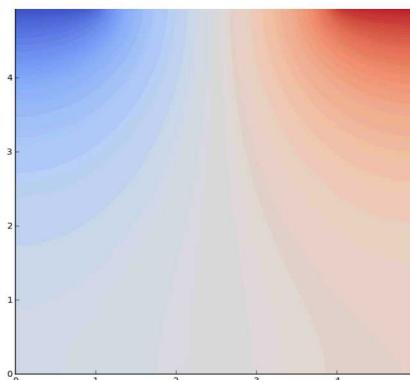
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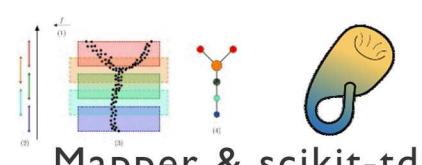
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Determine the intrinsic device topology using
TCAD-informed ML

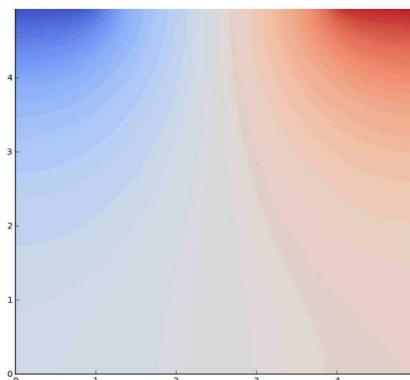


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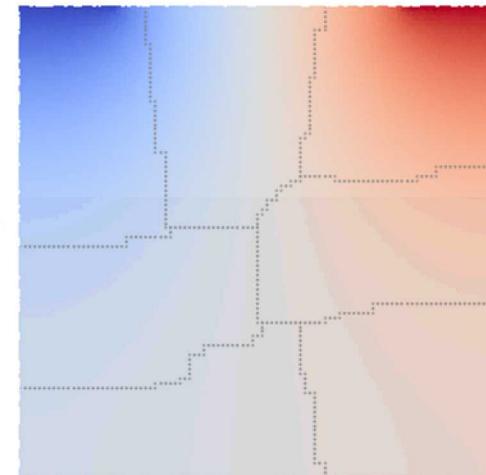
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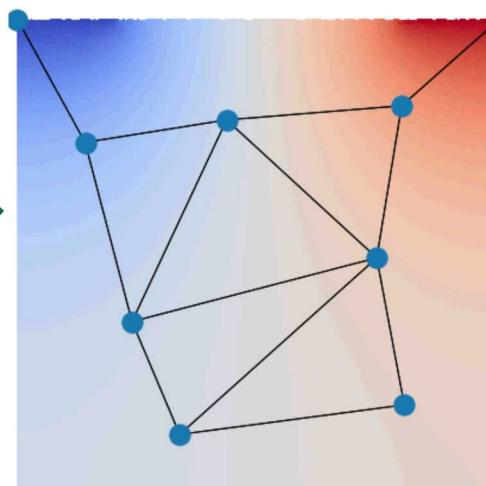
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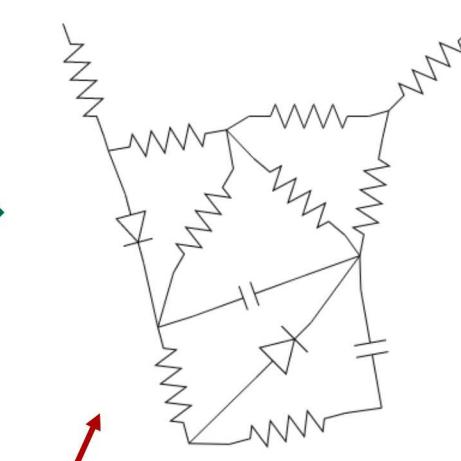
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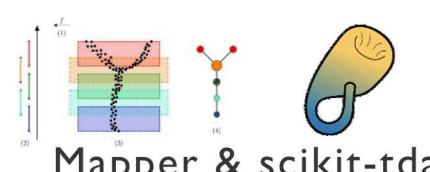
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**Loosely calibrated
TCAD simulations**



- Populate graph edges with components based on local responses from TCAD
- Enforce Kirchhoff's current law at each node during ML learning

pigNN-CMD Methodology

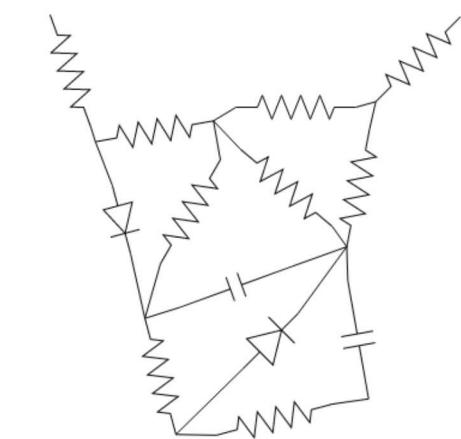
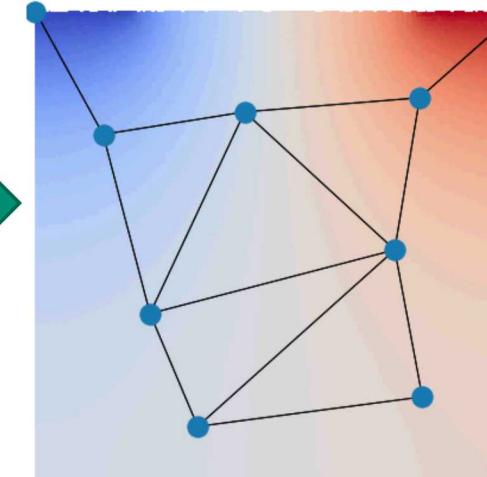
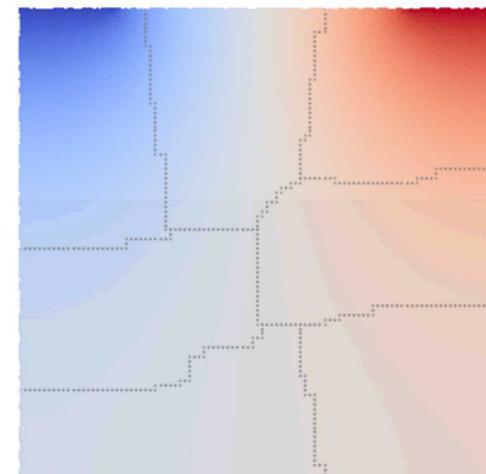
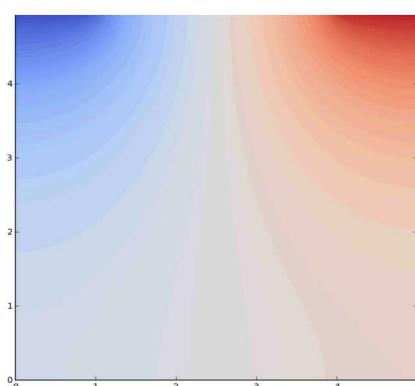
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TCAD simulations**

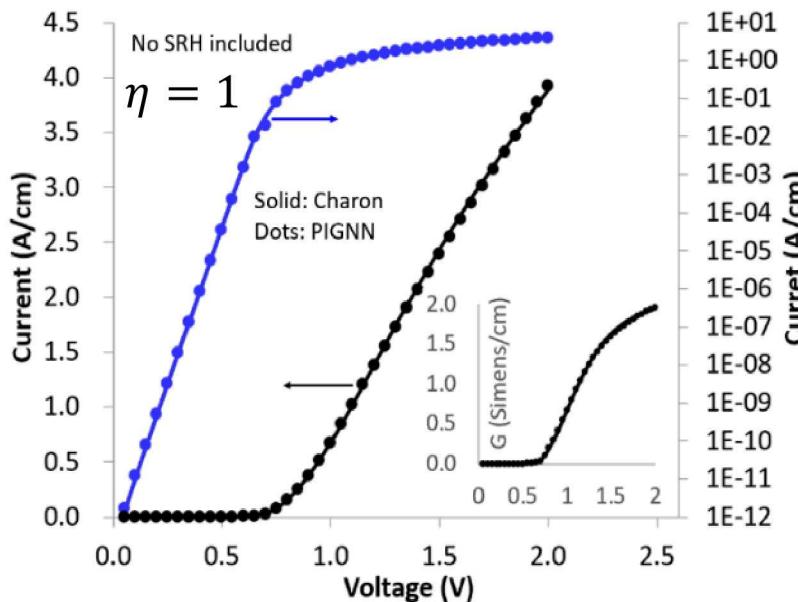
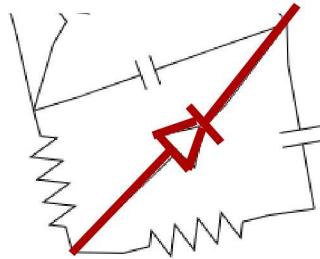


Train and Adapt
(using available experimental data)



Diode Compact Model for a pigNN-Graph Edge

What is a good compact model for a diode located at an edge?



- Apply TDA method with physical fields to isolate a localized diode
- Process TCAD physical fields to obtain response for the diode
- Apply data-driven neural network to develop compact model for the diode

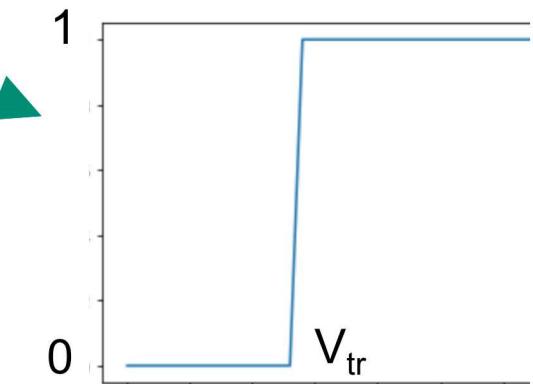
$$I_D = [1 - w(V_D)] I_0 \left(e^{\frac{qV_D}{\eta k_B T}} - 1.0 \right) + V_D G_D(V_D)$$

Voltage-dependent conductance learned using neural network

$$G_D(V_D) = w(V_D) \left(1 - \frac{V_{tr}}{V_D} \right) G_0 + w(V_D) \left(1 - \frac{V_{tr}}{V_D} \right) G_{NN}(V_D)$$

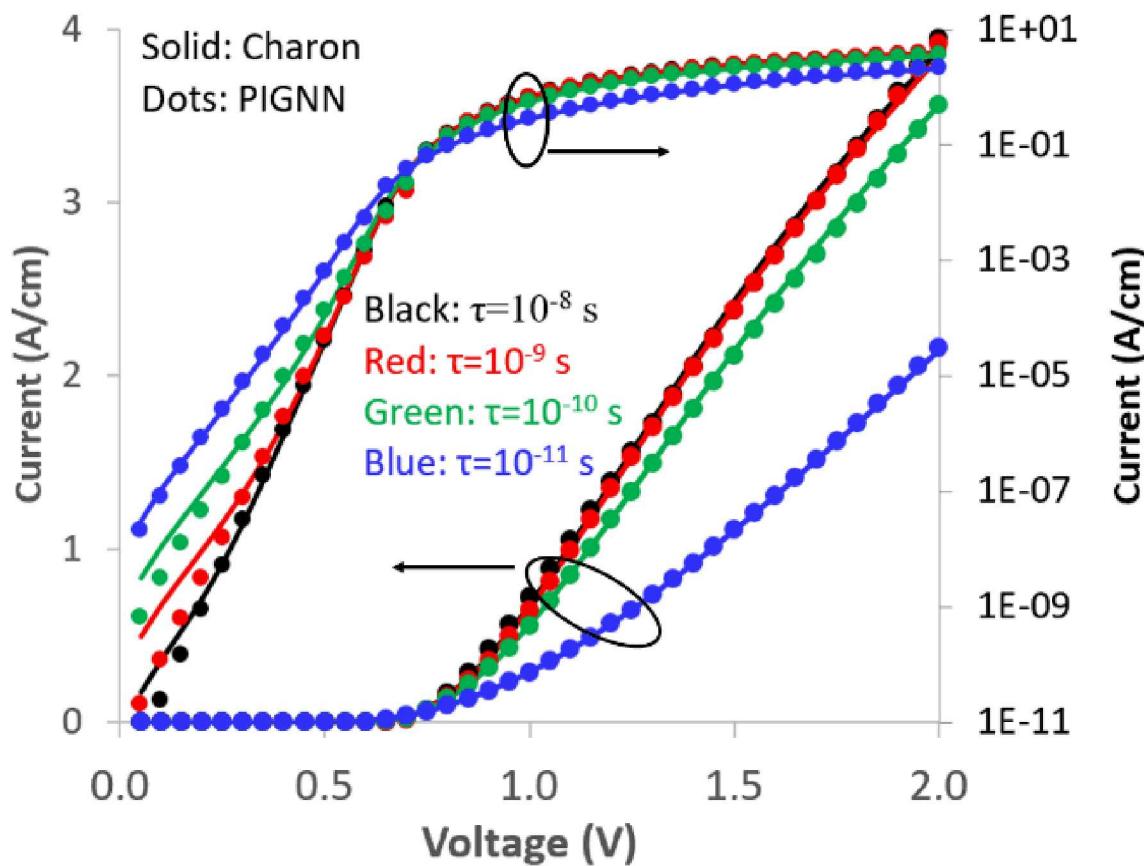
$$w(V_D) = 0.5[\tanh(10^5(V_D - V_{tr})) + 1.0]$$

A differentiable function that transitions the diode response smoothly from an exponential region to a quasi-linear region



Voltage Independent Non-ideality Factor

- Recombination effect increases the diode current in the low forward bias region
- **Voltage-independent** non-ideality factor partially captures the recombination effect



$$I_D = [1 - w(V_D)]I_0 \left(e^{\frac{qV_D}{\eta k_B T}} - 1.0 \right) + V_D G_D(V_D)$$

$\tau \text{ (s)}$	$I_0 \text{ (A/cm)}$	η
No SRH	1.71×10^{-13}	1.0
10^{-8}	1.35×10^{-12}	1.13
10^{-9}	5.14×10^{-12}	1.21
10^{-10}	2.37×10^{-10}	1.46
10^{-11}	1.02×10^{-8}	1.75

NN-learned Variables

Voltage independent non-ideality factor cannot accurately model the voltage dependent recombination effect.

NN Loss Function Design for Diode Compact Model

- Recombination effect is inherently voltage dependent
- Need **voltage-dependent** non-ideality factor to accurately capture the recombination effect

$$I_D = [1 - w(V_D)]I_0 \left(e^{\frac{qV_D}{\eta(V_D)k_B T}} - 1.0 \right) + V_D G_D(V_D)$$

$$\eta(V_D) = 1 + \eta_{NN}(V_D) \leftarrow \text{Voltage-dependent non-ideality factor learned using NN}$$

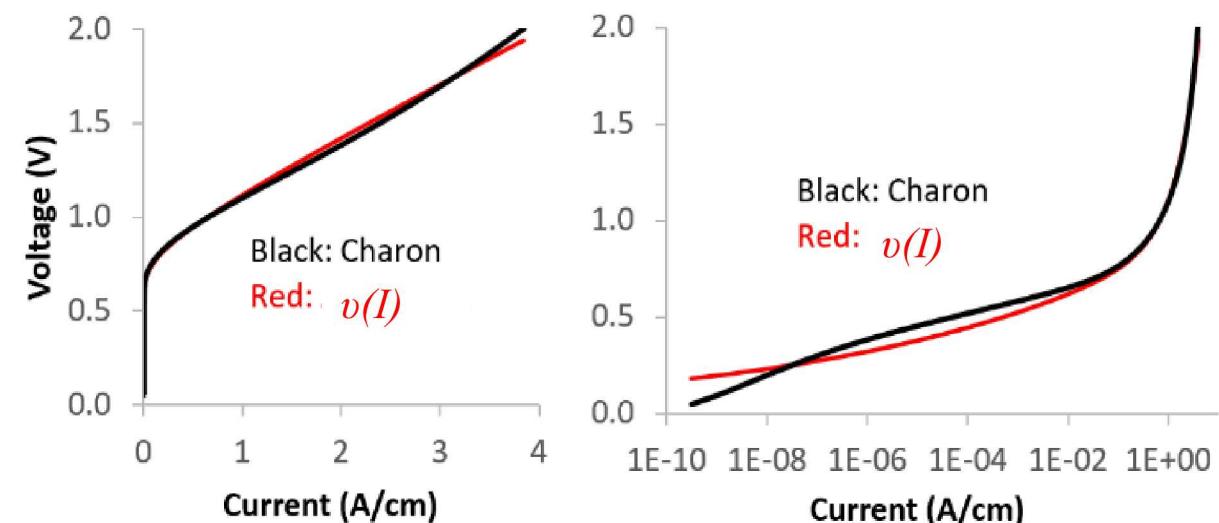
- A good NN loss function is needed to achieve accurate results due to mixture of exponential and quasi-linear current response

Proposed NN loss function:

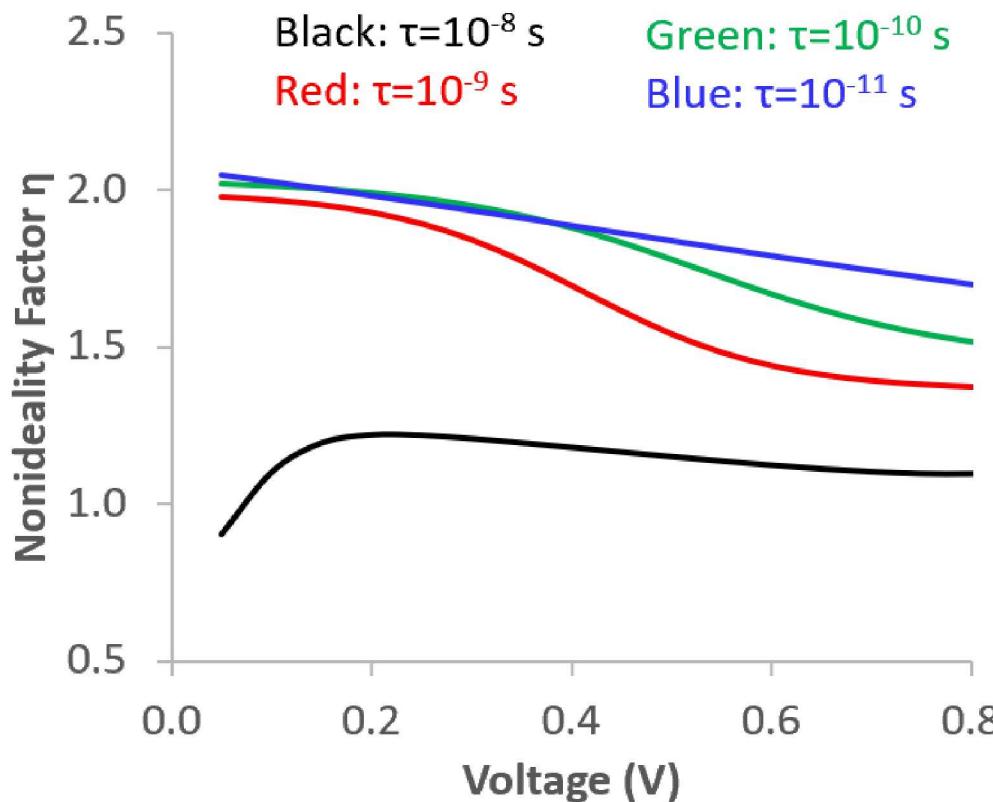
$$\mathcal{L} = [v(I_{NN}) - v(I_t)]^2 / [v(I_t)]^2$$

$$\downarrow v(I) = (aI)^b \times \tanh(dI - e) + fI$$

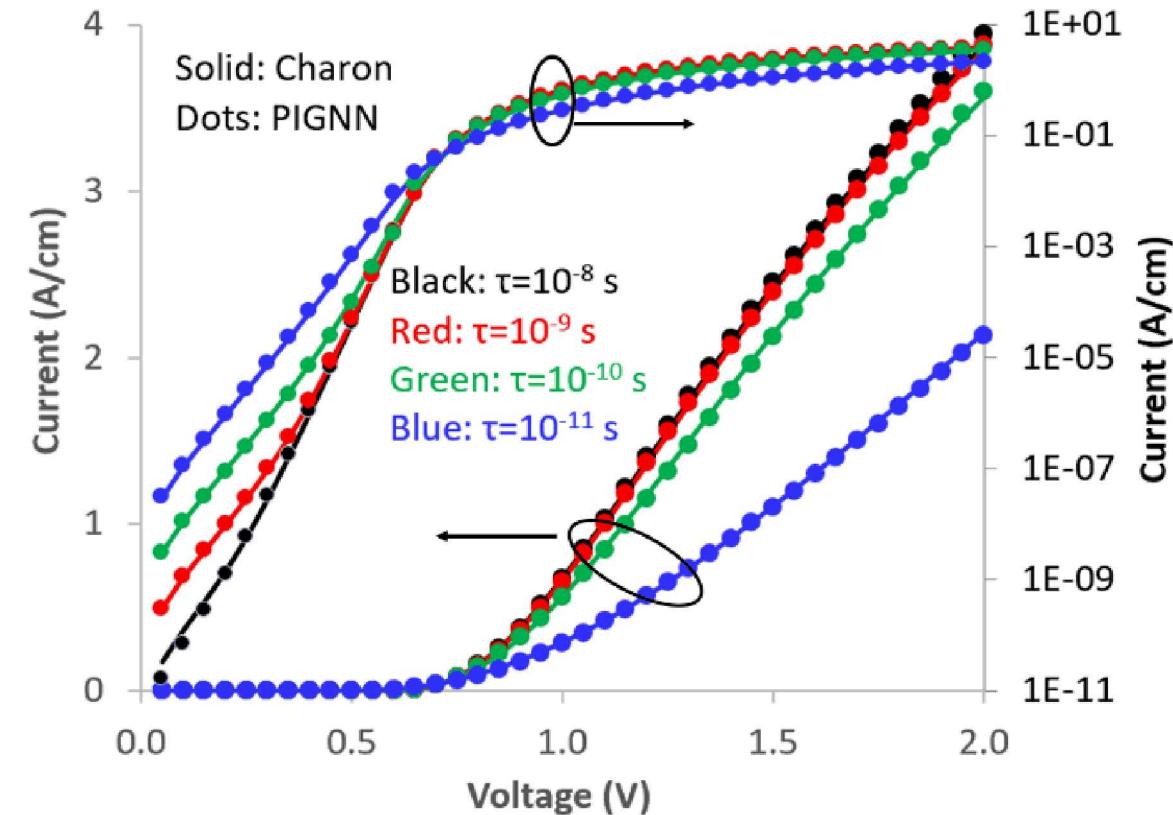
- ✓ Map the logarithmically separated current range to a linearly separated voltage range
- ✓ Use regression to determine a, b, d, e, f



Voltage Dependent Non-Ideality Factor



NN-learned non-ideality factor indeed shows a strong voltage dependence.



Voltage-dependent non-ideality factor allows us to accurately model the recombination effect.

Summary

- Presented the pigNN methodology for compact model development that brings together data-driven ML, TCAD, and existing compact models.
- Developed accurate compact model for a non-ideal PN diode that represents a non-linear edge in a pigNN graph
- Applying the pigNN methodology to other semiconductor devices (e.g., bipolar transistor) & other engineering areas (e.g., mechanics, EM).

